THE KENYA POLYTECHNIC UNIVERSITY
COLLEGE
DEPARTMENT OF INSTITUTIONAL MANAGEMENT
DIPLOMA IN CLOTHING TECHNOLOGY
END OF YEAR I EXAMINATIONS
NOVEMBER 2007 SERIES
PATTERN DRAFTING PRACTICAL
4 hours

Instructions to Candidates

A  You should have the following for this examination.
   •  H pencils
   •  30cm ruler
   •  ¼ scale ruler
   •  French curves
   •  Tracing wheel
   •  Paper scissors
   •  Set squares
   •  Eraser
   •  Glue
   •  Pins

B  You will be provided with the following
   •  Plain paper size A4
   •  Bodice and sleeve block

C  All stages of development must be shown on the answer sheet.
   Final patterns must have all pattern instruction.

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**TASK**

1. Using the measurements provided, draft patterns for the tailored skirt block

   **Measurements**
   - Waist: 68cm
   - Hips: 93cm
   - Waist to Hips: 20.6cm
   - Skirt length: 60cm

2. Trace out the child’s bodice and sleeve block provided and develop patterns for the dress style sketched below